

Aqueous dissolution rate of nuclear waste glasses as a function of environmental parameters

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3rd Summer School on nuclear and industrial glasses for energy transition

3rd Sumglass 2023, in Nimes, September 25-29, 2023

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Micro-Channel as a New Tool to Investigate Glass Dissolution Kinetics

2nd SumGLASS 2013

***Yaohiro INAGAKI
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Fukuoka, Japan***

***2nd International Summer School on Nuclear Glass Wasteform
SumGLASS 2013, at the site of Pont du Gard, September 26, 2013***



*INSIDE the CHANNEL (MACRO rather than
Constructed on Pont du Gard*

*THANK YOU FOR YOUR ATTENTION!
MERCI POUR VOTRE ATTENTION!*

ご清聴ありがとうございます。

2nd SumGLASS 2013

Need for evaluation of glass dissolution kinetics

Assessment of HLW glass performance in long-term geological disposal with reliability requires;

- (1) Reliable modeling based on scientific principles with **sound understanding of reaction mechanism.*****
- (2) Parameterization of mechanistic models to determine glass dissol. (alteration) rate as a function of environmental parameters.***

Dissolution rate = function (C_i , pH, temp, time, ...)



We need

“Reliable evaluation of glass dissolution kinetics”

“Kinetic evaluation”= evaluation of reaction rate as a function of parameters based on reaction mechanism

How to evaluate glass dissolution kinetics ?

Experimental studies



Atomistic simulation studies



How to evaluate glass dissolution kinetics ?

Experimental studies



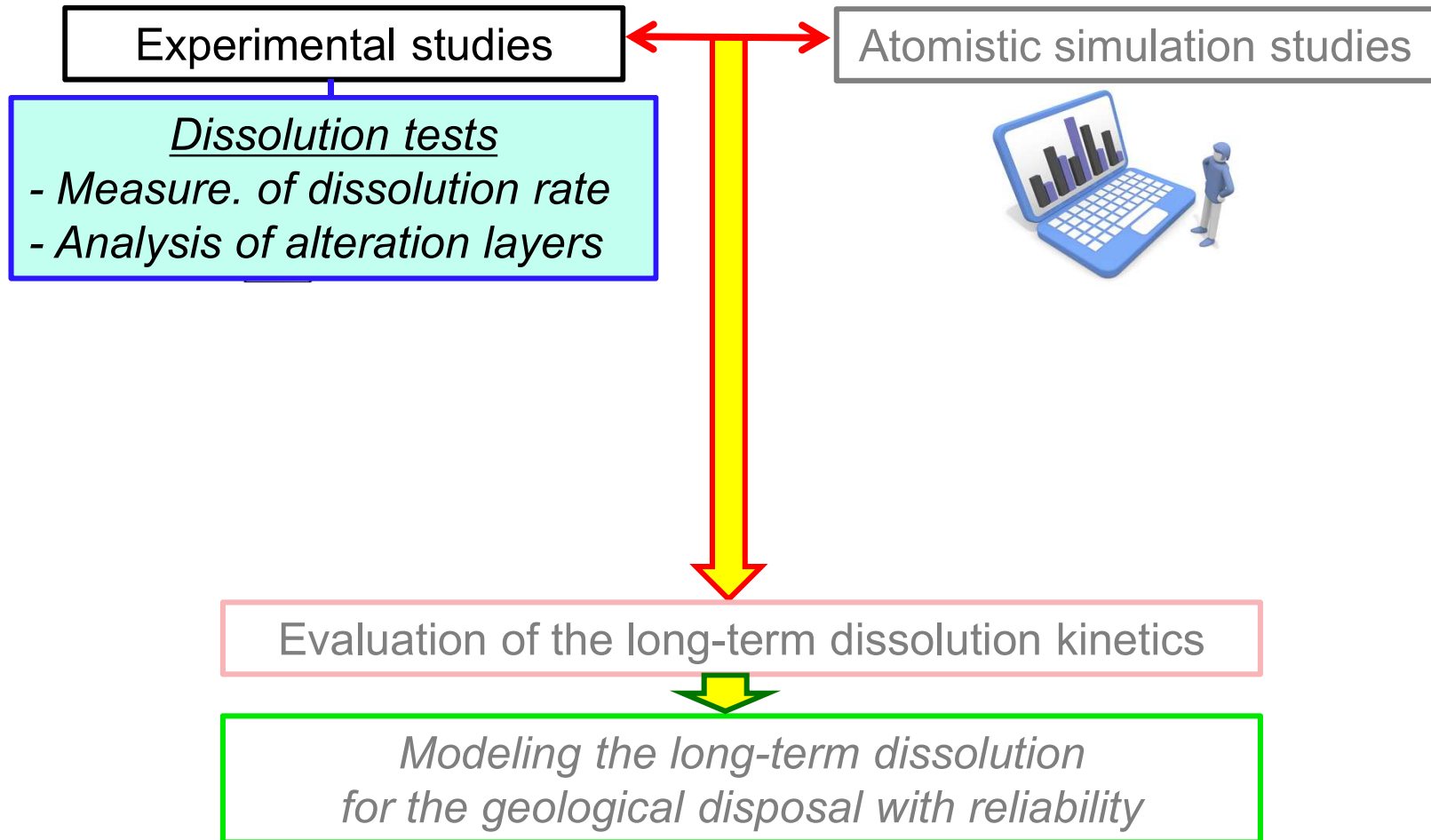
Atomistic simulation studies



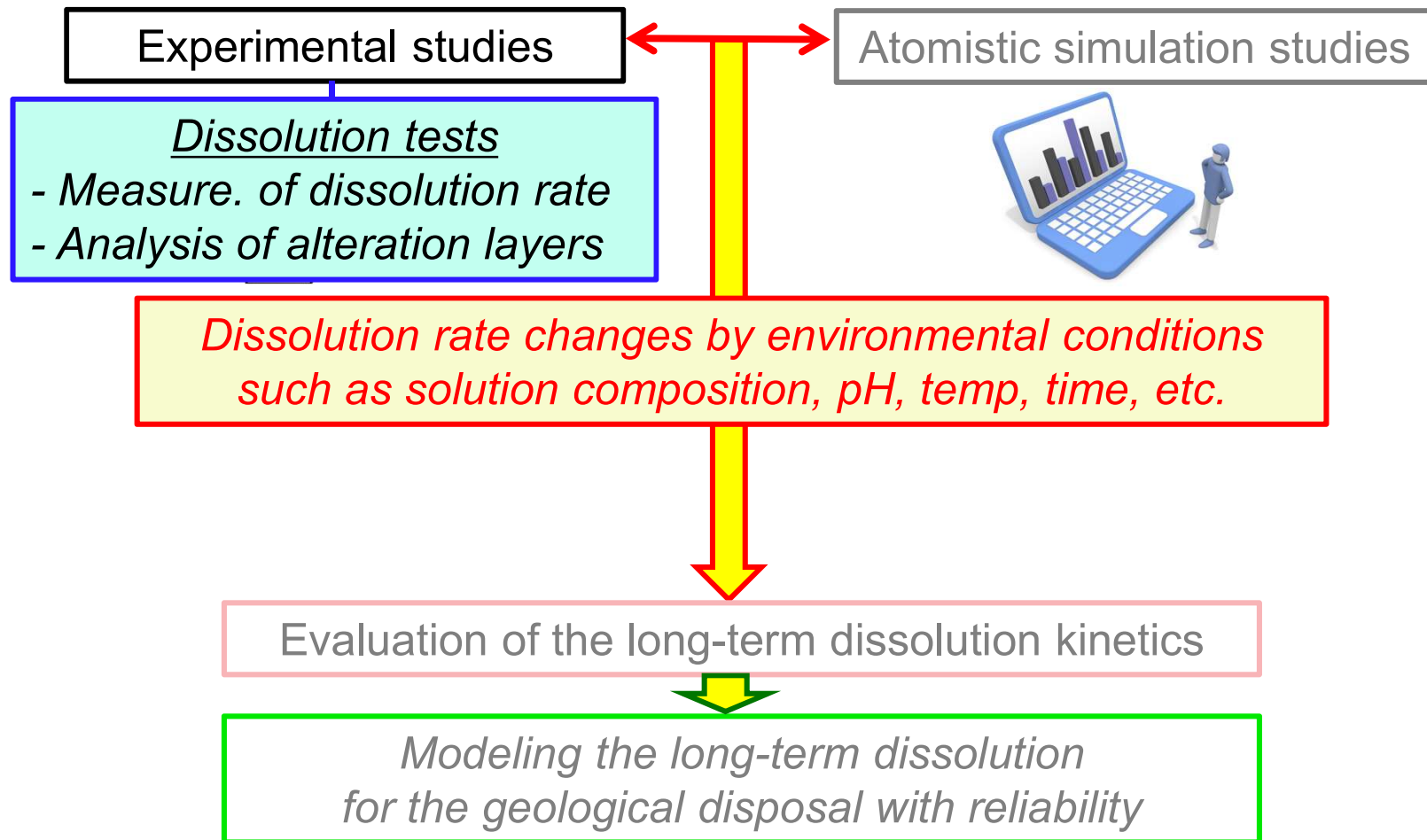
Evaluation of the long-term dissolution kinetics

*Modeling the long-term dissolution
for the geological disposal with reliability*

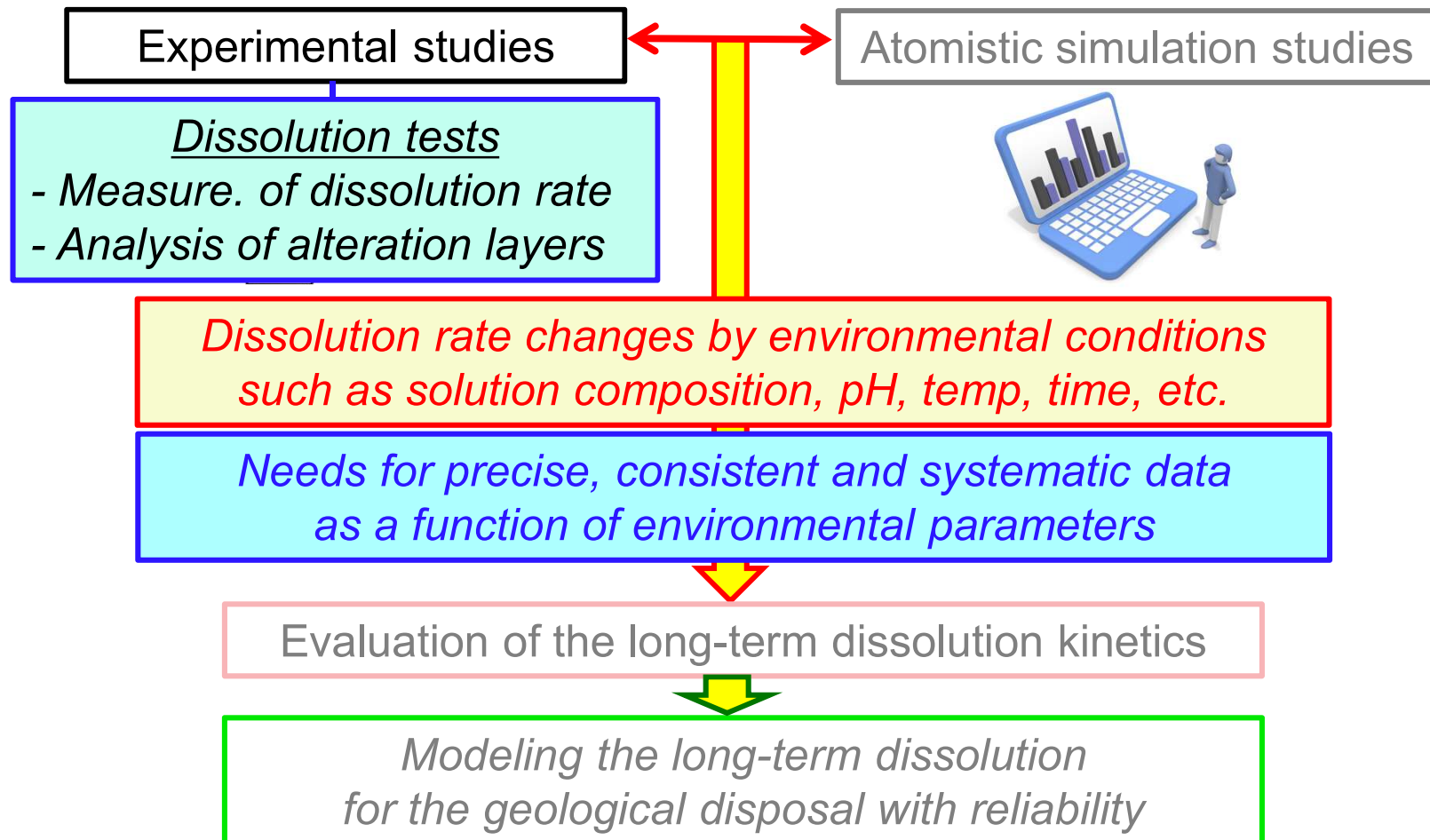
How to evaluate glass dissolution kinetics ?



How to evaluate glass dissolution kinetics ?



How to evaluate glass dissolution kinetics ?



Need for precise measurement of dissolution rate

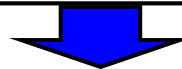
Evaluation of Glass Dissolution Kinetics

Dissolution rate = function (C_i , pH, temp, time,....)

- ***Sound understanding of reaction mechanism***
- ***Parameterization of mechanistic models***



Only a few data on glass dissolution rate available to the kinetic evaluation



Need for much more experimental data on glass dissolution rate with mechanism measured precisely, consistently, systematically as a function of environmental parameters

Test methods for measuring dissolution rate

Standard Test Methods for Durability of HLW glass

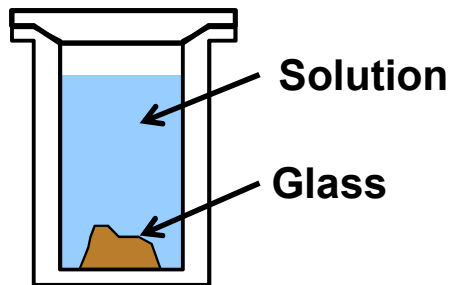
- ***MCC-1: Static leach test***
- ***MCC-2: Static, High-Temperature leach test***
- ***MCC-3: Agitated Powder leach test***
- ***MCC-4: Low-flow-rate leach test***
- ***MCC-5: Soxhlet leach test***
- ***PCT: Product consistency test***
- ***SPFT: Single-Pass Flow-Through test***
- ... ***VHT, ASTM, ISO, etc.***



***Unsuitable for measurement of dissolution rate
as a function of various environmental parameters***

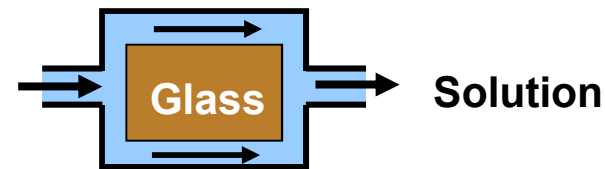
Types of test methods for measuring dissolution rate

Static Test



- Simple apparatus & operation
- High S/V ratio (powdered glass)
- Precise solution measurement
- Solution conditions **Uncontrolled** (pH, composition, etc)

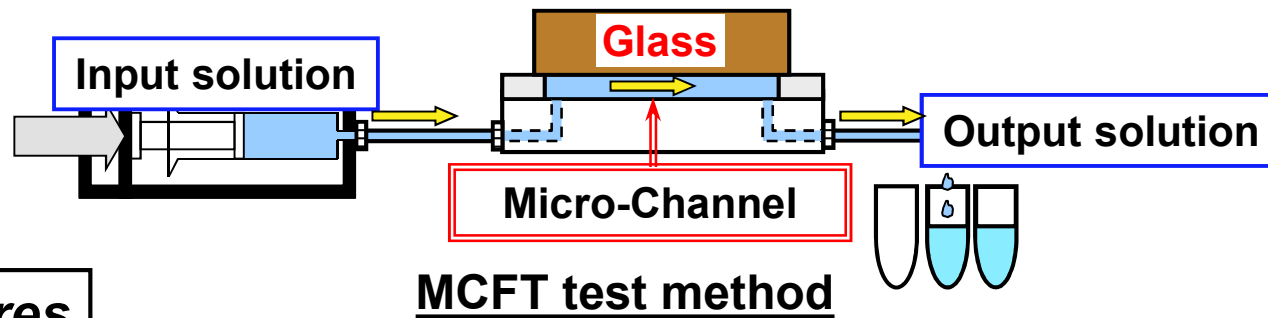
Flow-Through Test



- **Controlled** const. solution condition
- Intricate apparatus & operation
- Usually low S/V ratio
- Large experimental errors

“Flow-through test” is suitable for measurement of dissolution rate as a function of environmental parameters, however, we should **improve / develop test method for precise measurement.**

Features of Micro-Channel Flow-Through test method



Features

- **Flow-through method provides,**
 - **well-controlled constant solution conditions (pH, C_i , etc.).**
- **Use of coupon shaped glass specimen provides,**
 - **precise determination of reaction surface area, flow rate,**
 - **direct / totally quantitative analyses of reacted glass surface.**
- **Use of micro-channel reactor provides,**
 - **high S/V ratio leading to precise measurement of solution by ICP-MS.**

**Precise measurement of glass dissolution rate
as a function of environmental parameters**

Environmental parameters under disposal conditions

Modeling HLW glass performance in geological disposal requires

“Evaluation of dissolution kinetics under disposal conditions”.

Major environmental parameters to be considered

- ***Temp*** : a fundamental parameter of kinetics, varies with the site & period.
- ***pH*** : affects glass dissolution rate with mechanism, and varies with disposal site and period.
- ***Si*** : a major glass constituent, major element dissolved in ground water affecting glass dissolution rate, and the concentration varies with the site and period.

Reaction time: Form & growth of surface alteration layers



“Reliable & precise data of glass dissolution as a function of Temp, pH and Si concentration.

Initial dissolution rate, r_0 , as a function of pH & temp

Definition of glass dissolution rate

Normalized dissolution rate of element i

$$NR_i \text{ [g/m}^2\text{/d]} \equiv \frac{dNL_i}{dt} = \frac{C_i}{\Delta t} \frac{1}{f_i} \frac{V}{S}$$

C_i : Conc. of element i in output solution at each sampling

Δt : Each sampling period

f_i : Mass fraction of element i in original glass

V : Output solution volume at each sampling

S : Geometric glass surface area in contact with solution

Glass dissolution rate, r

$$r \equiv NR_{Si} \text{ [g/m}^2\text{/d]}$$

Initial dissolution rate, r_0 , in 1st-order dissolution rate law

$$r = r_0 (1 - Q/K) + r_{residual} = r_0 (1 - C_{Si}/C_{sat}) + r_{residual}$$

$$r_0 \equiv NR_{Si} \text{ at } C_{Si} \simeq 0$$

Glass specimens used for MCFT test

ISG: International Simple Glass

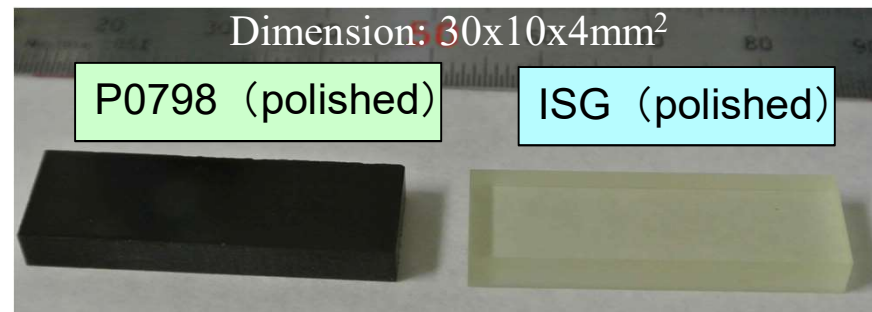
ISG	SiO ₂	B ₂ O ₃	Na ₂ O	Al ₂ O ₃	CaO	ZrO ₂	Others
wt%	56.2	17.3	12.2	6.1	5.0	3.3	-

P0798: Japanese reference glass

P0798*	SiO ₂	B ₂ O ₃	Na ₂ O	Al ₂ O ₃	CaO	ZrO ₂	Others**
wt%	46.6	14.2	10.0	5.0	3.0	1.5	19.7

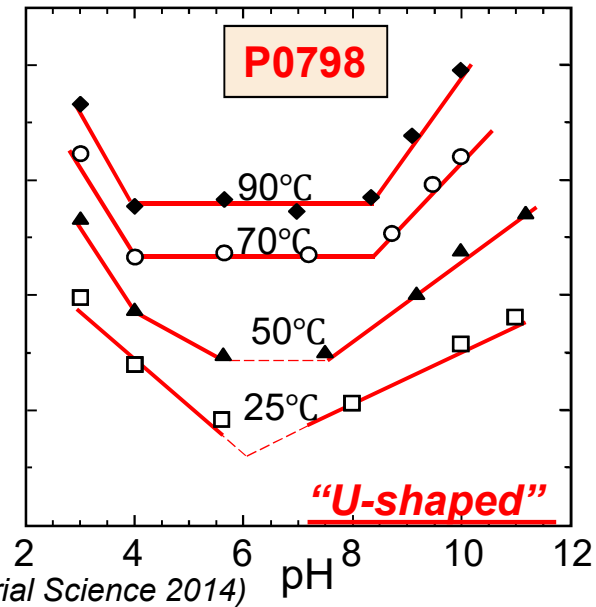
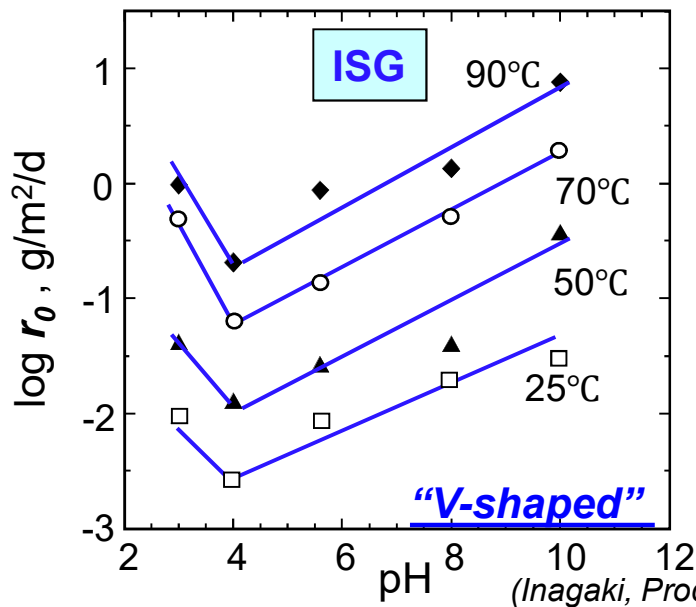
*P0798 has a composition **close to French SON68**

**Others: Li₂O, ZnO, Fe₂O₃, MoO₃, CeO₂, Nd₂O₃, Cs₂O, etc., total 28 elements



Test results: Initial dissolution rate, r_0 (pH, temp)

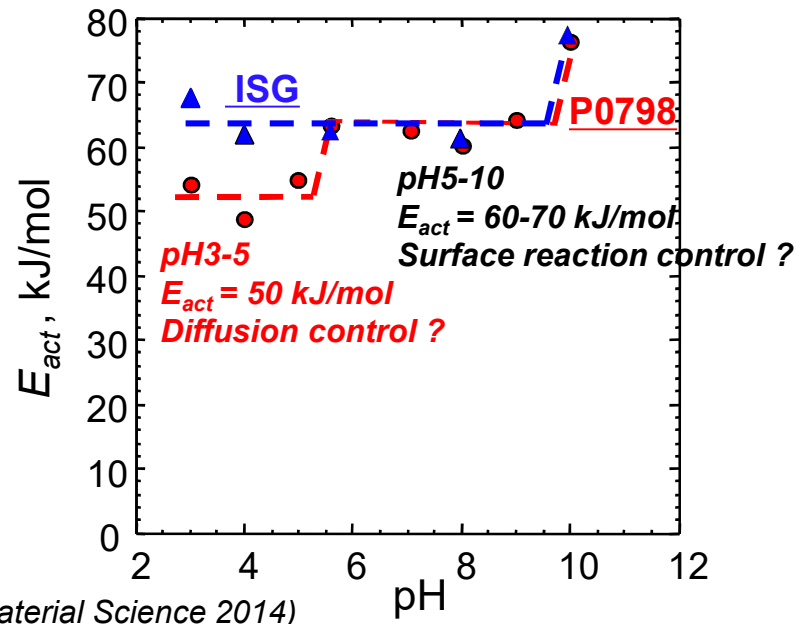
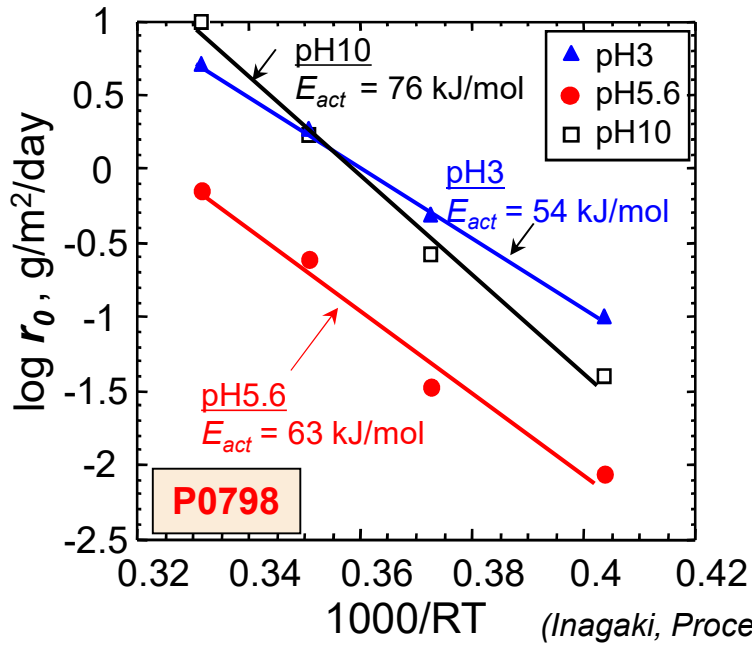
Initial dissolution rate, r_0 , as a function of pH and temp by MCFT
ISG vs P0798



ISG \Rightarrow "V-shaped" pH dependence at the bottom pH4
P0798 \Rightarrow "U-shaped" pH dependence at the bottom pH6

Test results: Initial dissolution rate, r_0 (pH, temp)

Activation energy E_{act} of r_0 as a function of pH by MCFT
ISG vs P0798



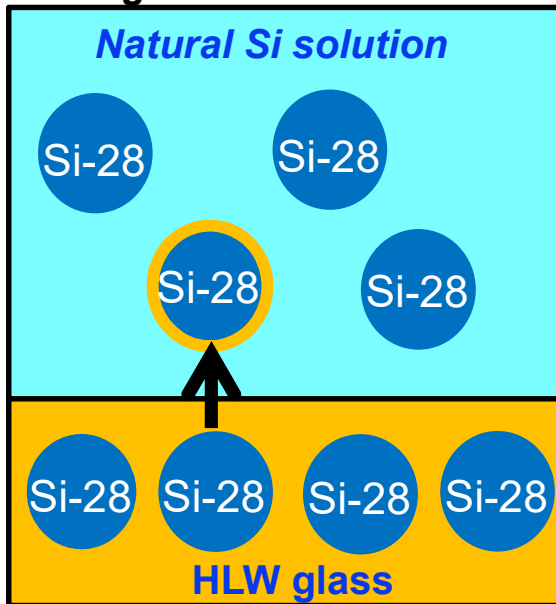
A certain difference in E_{act} between **P0798** and **ISG** at **acidic pH**
 The dissolution mechanism changes with pH and glass composition

Glass dissolution rate as a function of C_{Si} : Test

method

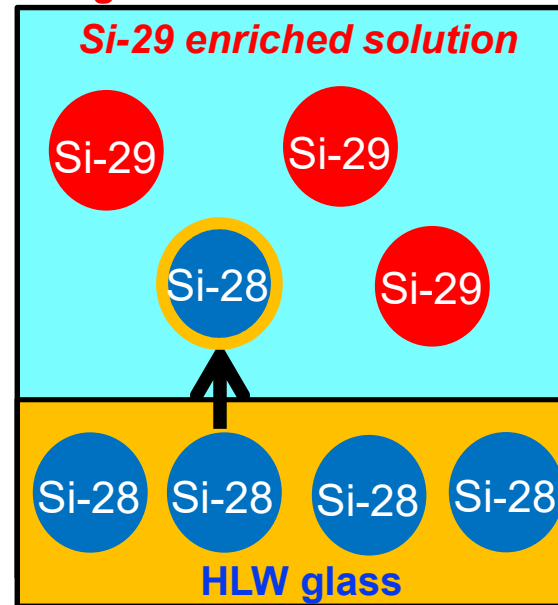
How to measure ? → MCFT test by using Si isotopes

Conventional test
using natural Si solution



Impossible to distinguish Si dissolved from glass into solution

Present test
using Si-29 enriched solution



Possible to distinguish Si-28 dissolved from glass into solution

Test method: Isotopic ratio of Si used for the test

Isotopic ratio of **natural Si** and **Si-29 enriched SiO₂** [at %]

	Si-28	Si-29	Si-30
Natural Si	92.22	4.69	3.09
Si-29 enriched SiO₂ (Isoflex USA)	0.14	99.21	0.65

Isotopic ratio of Si for glass and test solution [at %]

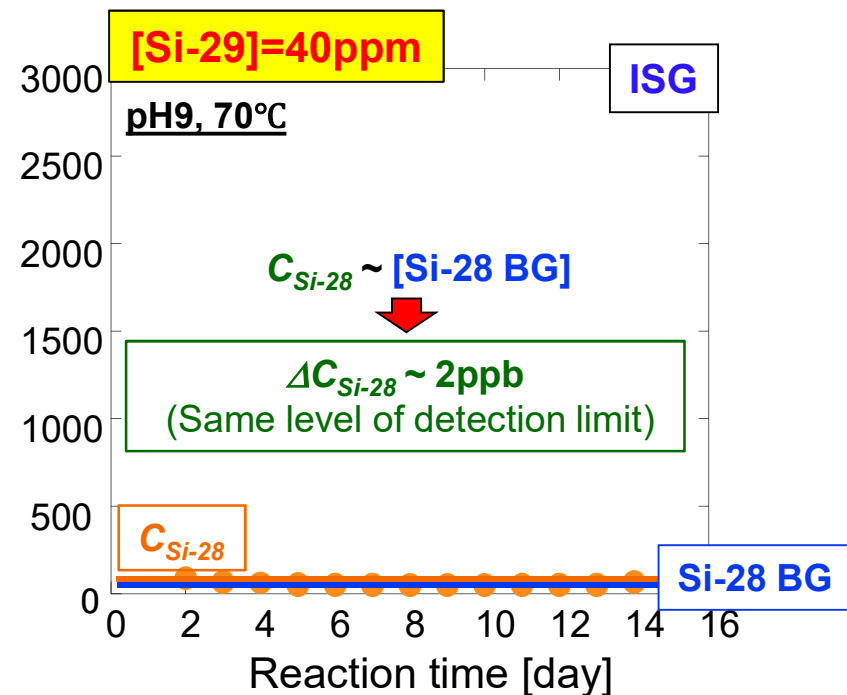
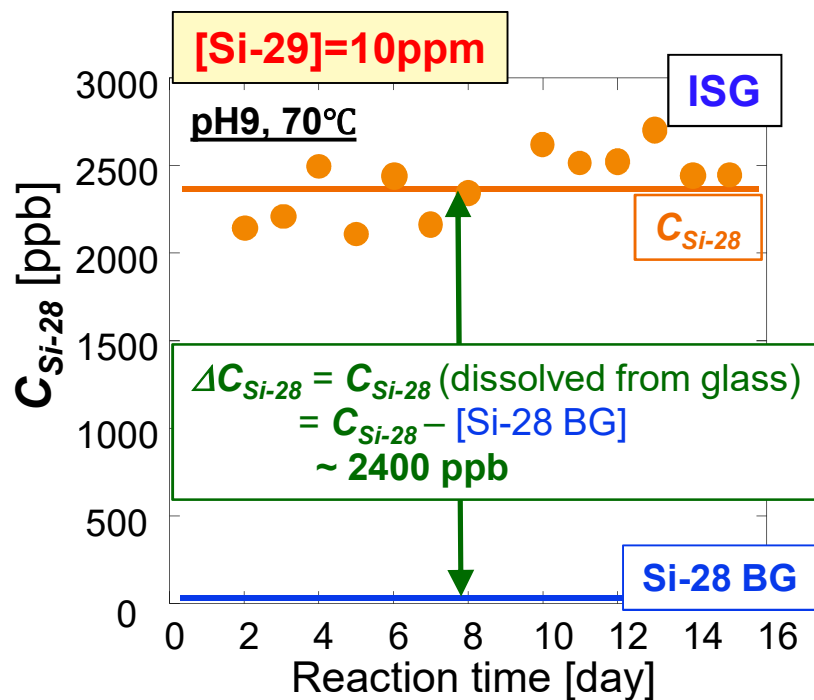
	Si-28	Si-29
Glass (P0798, ISG) (Natural Si)	92.22	4.69
Test solution containing Si (Si-29 enriched)	0.14	99.21



Concentration of Si-28 dissolved from glass into solution can be measured to determine the glass dissolution rate.

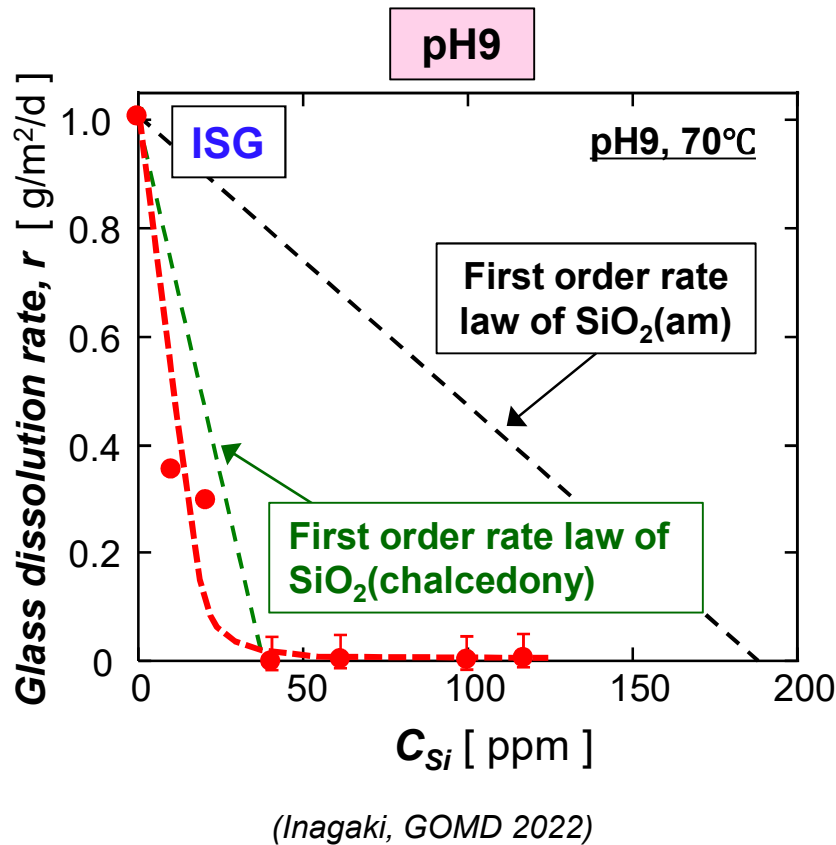
Test results: Glass dissolution rate, r (C_{Si})

Si-28 concentration in output solution measured for determination of glass dissolution rate at pH9



(Inagaki, GOMD 2022)

Test results: Glass dissolution rate, r (C_{Si}) at pH9



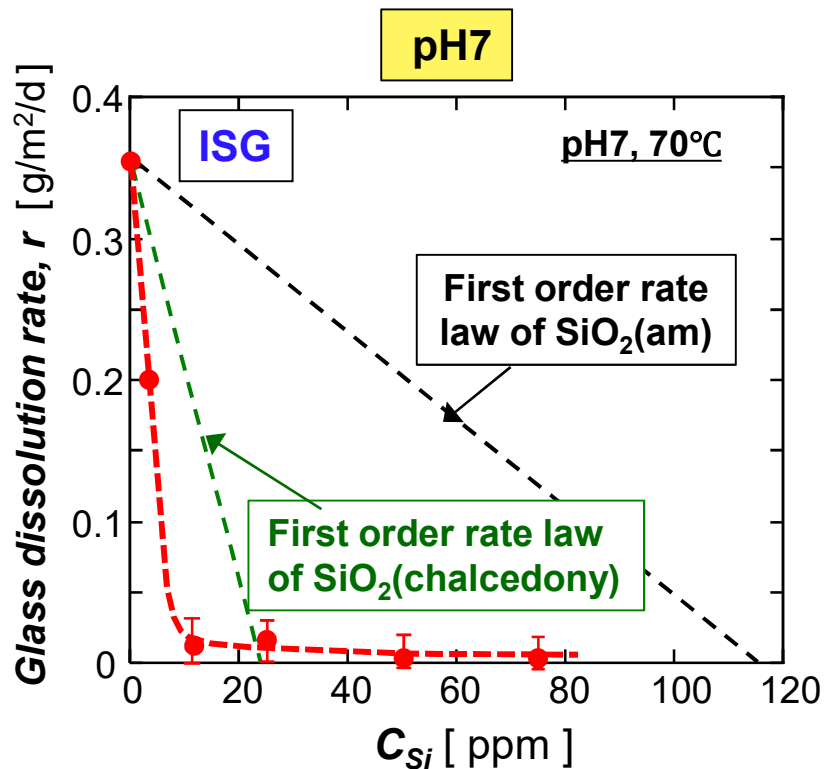
Glass dissolution rate at pH9:

- Decreases drastically with C_{Si} .
- Far from the first order rate law of $\text{SiO}_2(\text{am})$.
- Near that of $\text{SiO}_2(\text{chalcedony})$.
- But the shape differs from the first order rate law.

↓ suggests

- Not controlled by a simple surface reaction of SiO_2 ,
- Formation of surface alteration layer can affect the dissolution rate even in the early stage of dissolution.

Test results: Glass dissolution rate, r (C_{Si}) at pH7



(Inagaki, GOMD 2022)

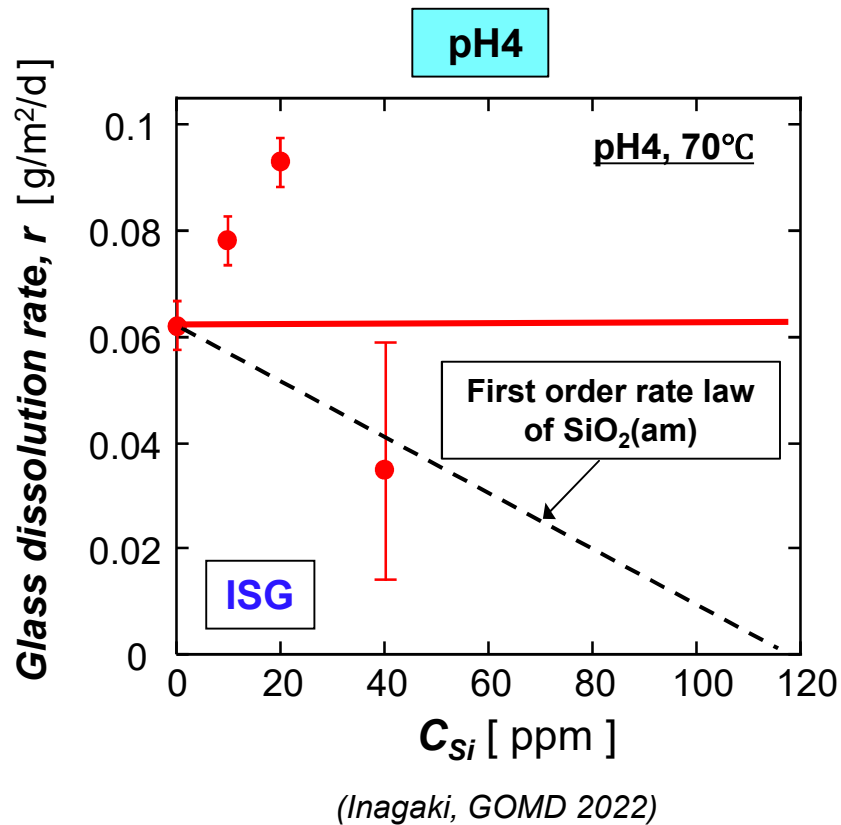
Glass dissolution rate at pH7:

- Similar behavior as at pH9.
- Decreases drastically with C_{Si} .
- Far from the first order rate law of $\text{SiO}_2(\text{am})$.
- The shape differs from the first order rate law.

suggests

- Not controlled by a simple surface reaction,
- Formation of surface alteration layer can affect the dissolution rate even in the early stage of dissolution.

Test results: Glass dissolution rate, r (C_{Si}) at pH4

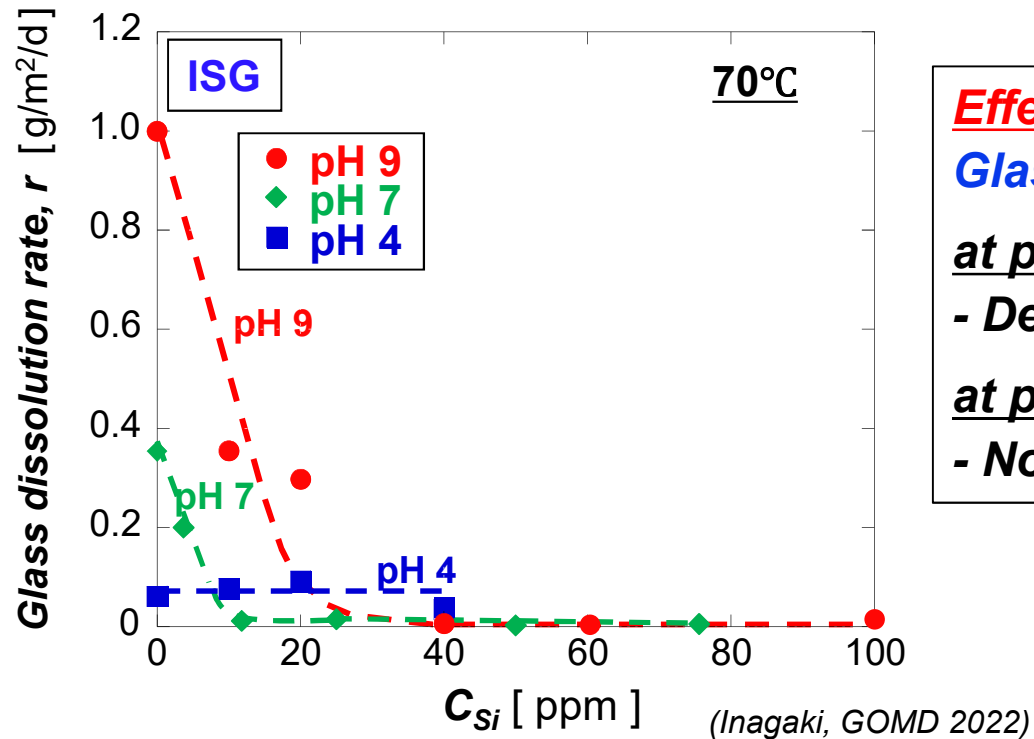


Glass dissolution rate at pH4:

- Quite different behavior from that at pH7,9.
- Slightly increases with C_{Si} ,
- Or not affected by C_{Si} .

- Controlled by a different mechanism from that at pH7,9.
- Different surface alteration layer may form at pH4,
- causing the different dissolution mechanism.

Test results: Glass dissolution rate, r (C_{Si} , pH)



Effects of C_{Si}

Glass dissolution rate, r :

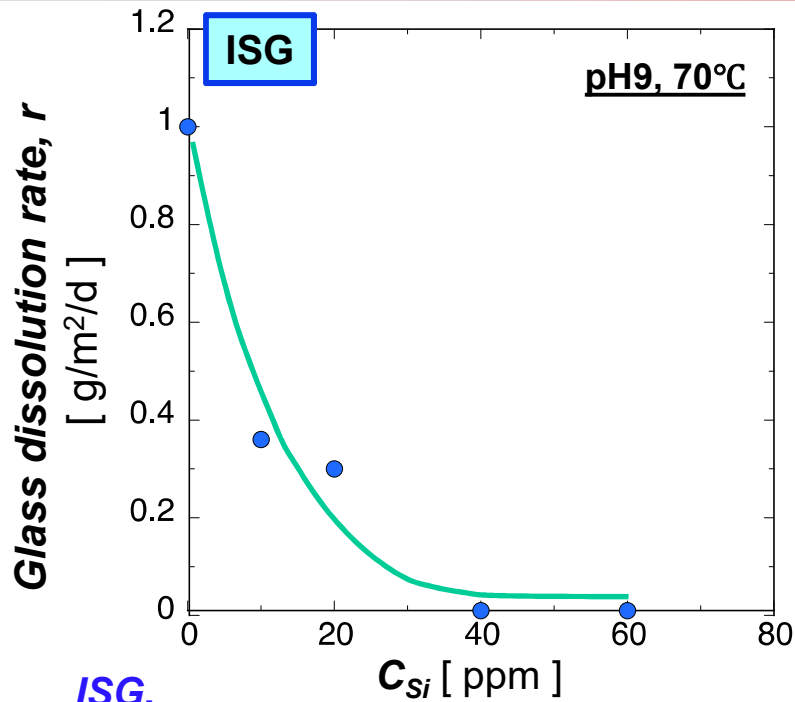
at pH9, pH7

- Decreases drastically with C_{Si} .

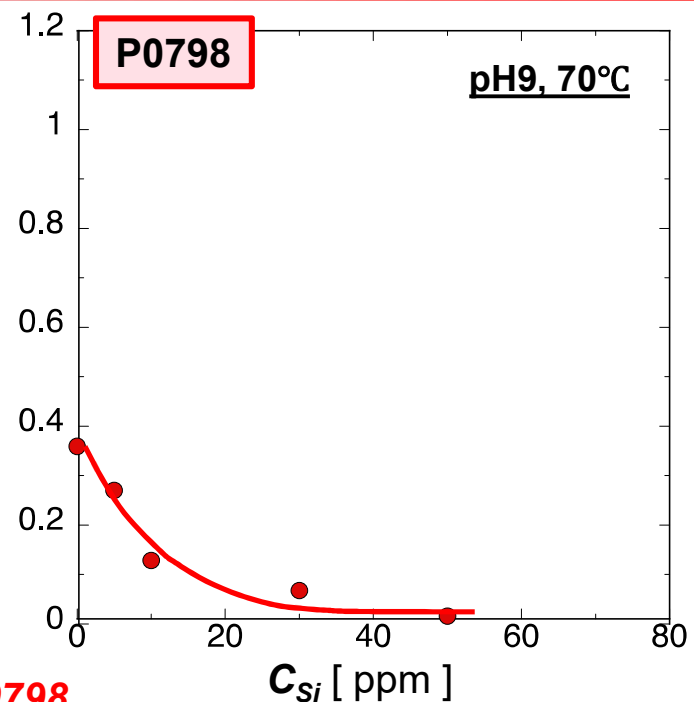
at pH4

- Not affected by C_{Si} .

Test results: Effect of glass type on r (C_{Si}) at pH9



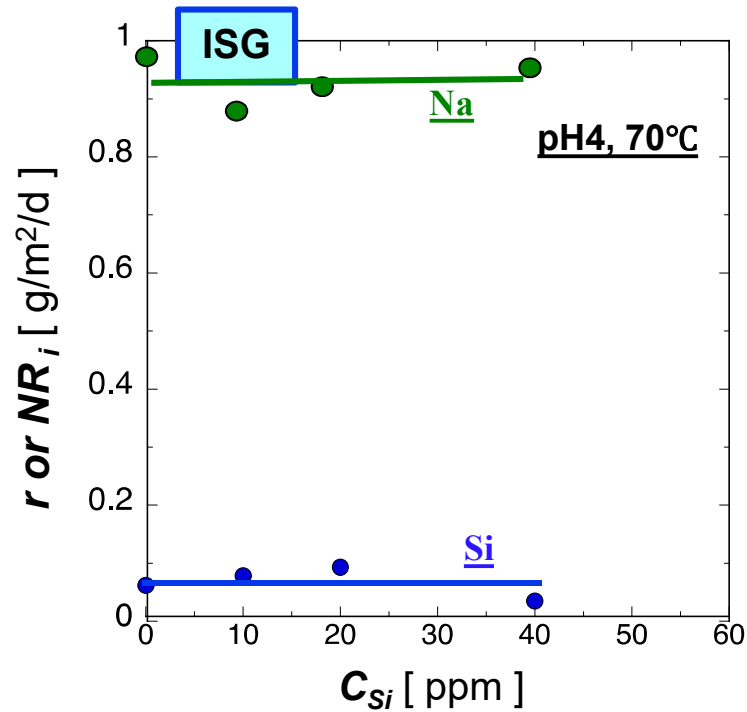
ISG,
non-linear relation between r vs C_{Si}



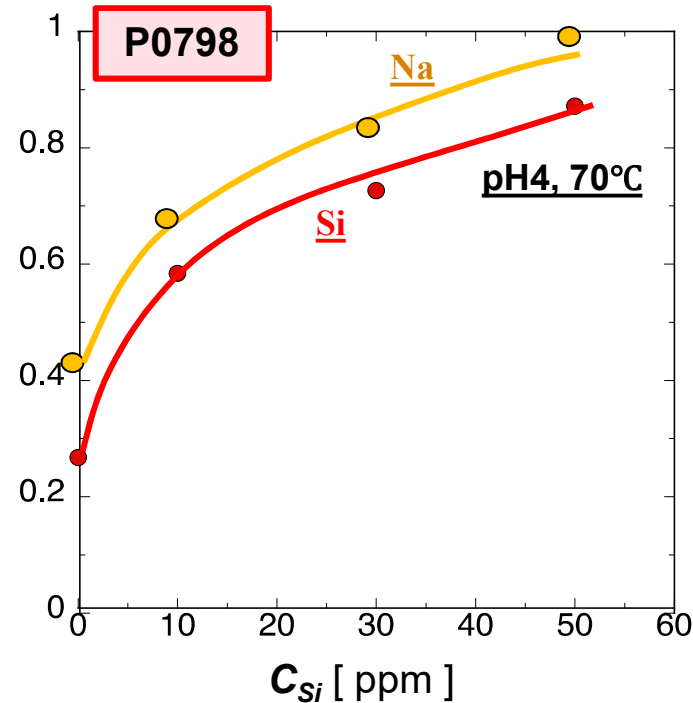
P0798,
non-linear relation between r vs C_{Si}

The similar rate controlling mechanism at pH9, 70°C between ISG and P0798

Test results: Effect of glass type on $r(C_{Si})$ at pH4



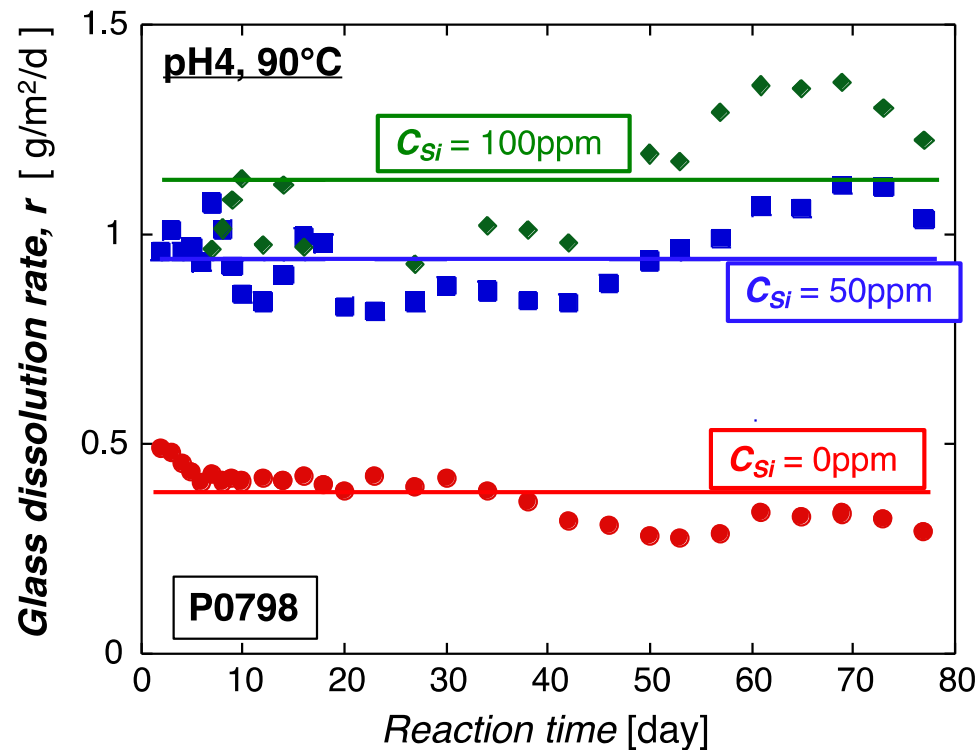
ISG: No C_{Si} dependency



P0798: Increases slightly with C_{Si}

- The glass dissolution rate for P0798 increases with C_{Si} at pH4 ?
- The data is correct ?

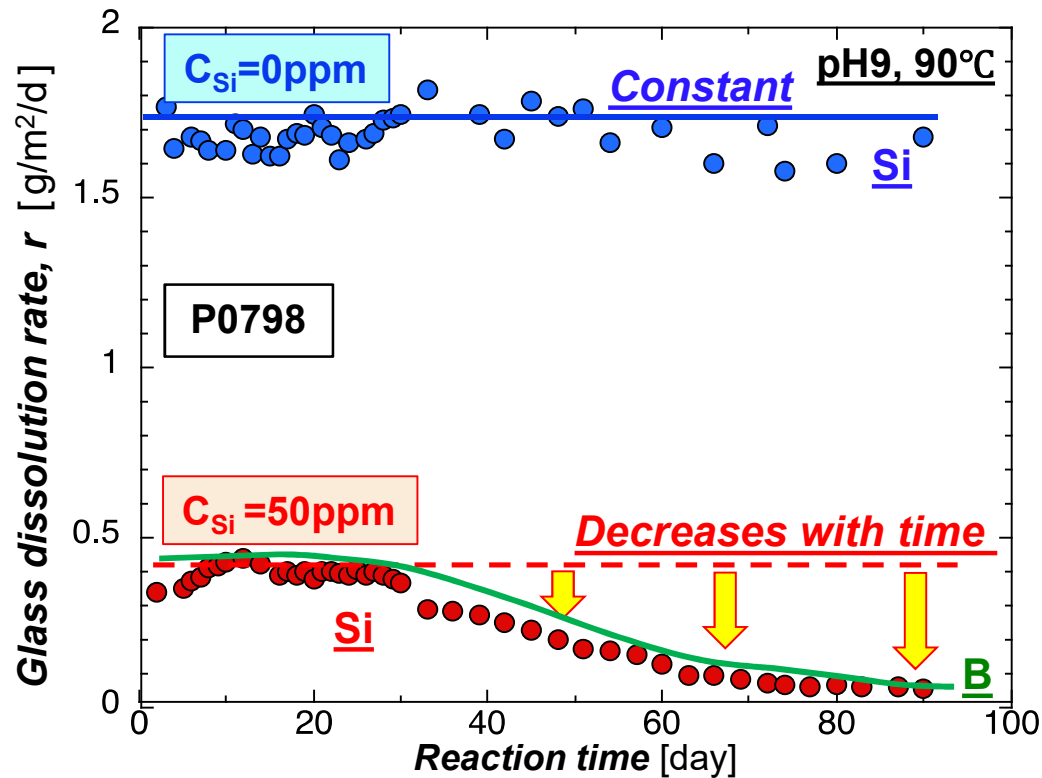
Re-test results: Dissolution rate of P0798, $r(C_{Si})$ at pH4



At pH4,

- Glass dissolution rate for P0798 increases with the Si concentration.
- How is the mechanism to explain the increase in r with C_{Si} ?

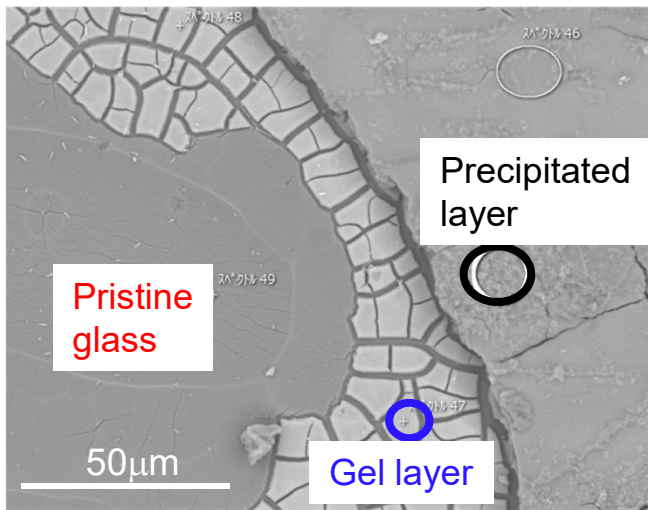
Test results: Effect of C_{Si} on $r(t)$ at pH9, 90°C



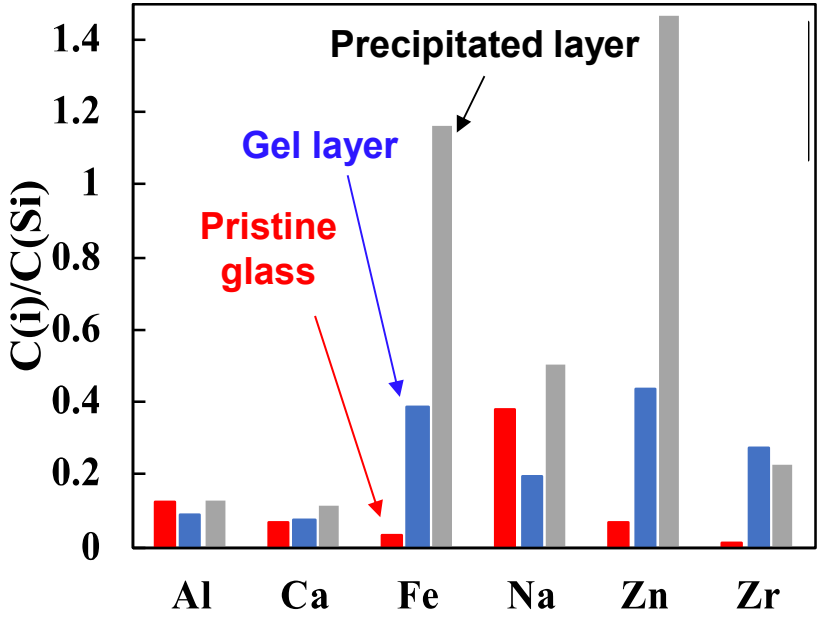
- At $[Si] = 50$ ppm, r decreases with time after 30 days.
- Effects of formation & growth of protective surface layer ?

SEM-EDX Analysis of altered surface layers ($C_{Si} = 0$)

[Si]=0ppm, pH9, 90°C, 90days
 → **Constant r with time**



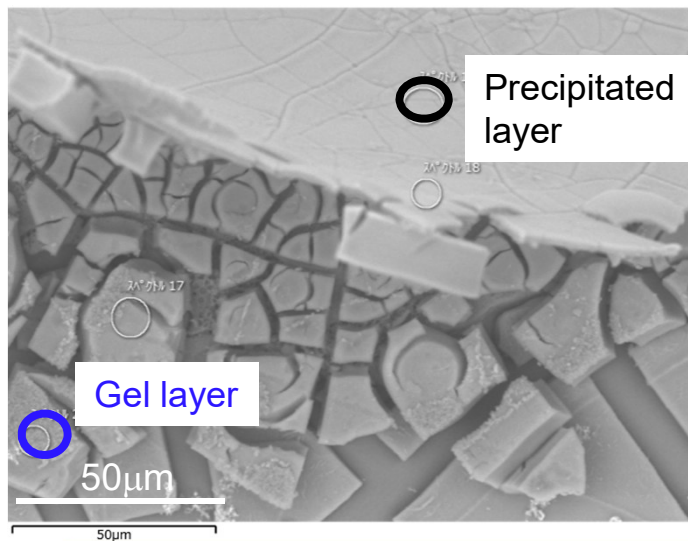
Relative atomic ratio to Si by EDX



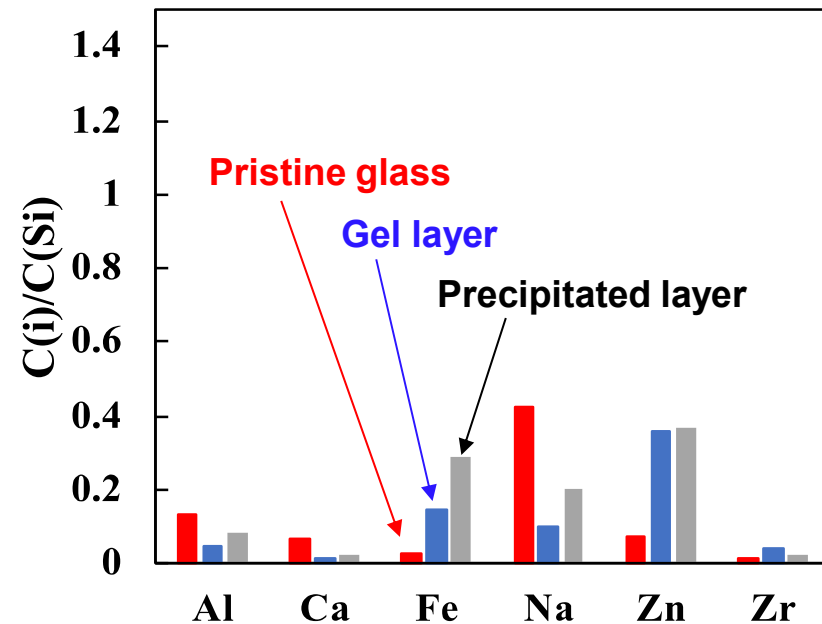
In case of [Si] = 0ppm
Insoluble elements, such as Fe, Zn, concentrated in the layers
 → **Layers rich in soluble elements form to be not protective**

SEM-EDX Analysis of altered surface layers ($C_{Si} = 50\text{ppm}$)

[Si]=50ppm, pH9, 90°C, 90days
→ **Decrease in r with time**



Relative atomic ratio to Si by EDX



In case of [Si]=50ppm

Concentration of Si is high in the layers

→ **Si-rich layers form and grow to be protective**

Summary, Conclusions or Proposal ? (1)

- An assessment of the long-term waste glass performance requires reliable modeling of the glass dissolution rate based on scientific principles.***
- For the reliable modeling, we need reliable evaluation of the glass dissolution kinetics.***
- The only way to complete the reliable kinetic evaluation is a high-level integration of experimental & simulation studies with consistency.***
- The experimental study should provide the precise, consistent & systematic data on glass dissolution rate as a function of environmental parameters for the reliable kinetic evaluation.***

Summary, Conclusions or Proposal ? (2)

- ***We measured the glass dissolution rate as a function of environmental parameters, and the results show followings,***
- ***The dissolution rate changes depending on environmental parameters complicatedly rather than we had expected.***
- ***The dissolution rate with mechanism is suggested to be affected by types & properties of the alteration layers, which can change sensitively by environmental parameters.***
- ***Consequently, we need much more experimental data on the glass dissolution rate & alteration layers measured precisely, consistently & systematically as a function of environmental parameters for the reliable kinetic evaluation.***

THANK YOU FOR YOUR ATTENTION!

MERCI POUR VOTRE ATTENTION!

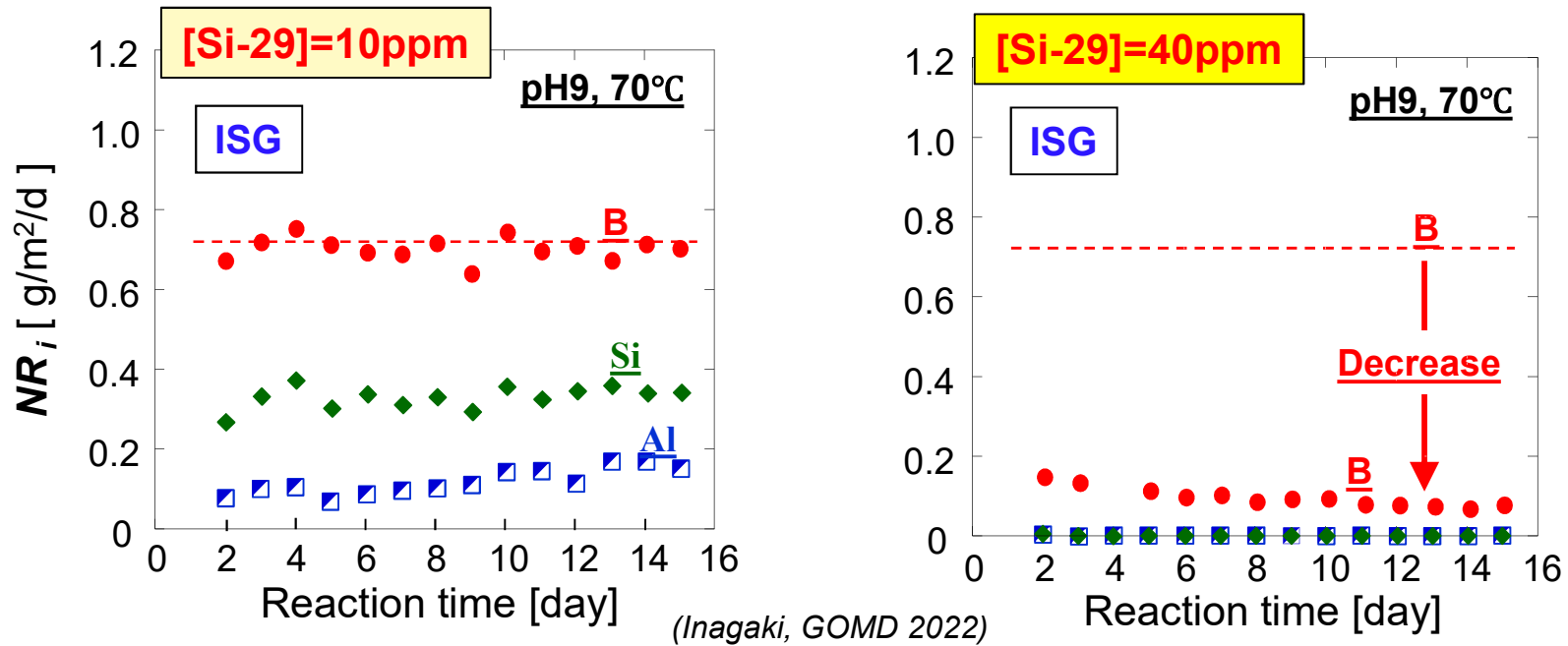


Arenes de Nîmes,

An excellent stone vessel with large size, suitable for static test ?

Extra Files

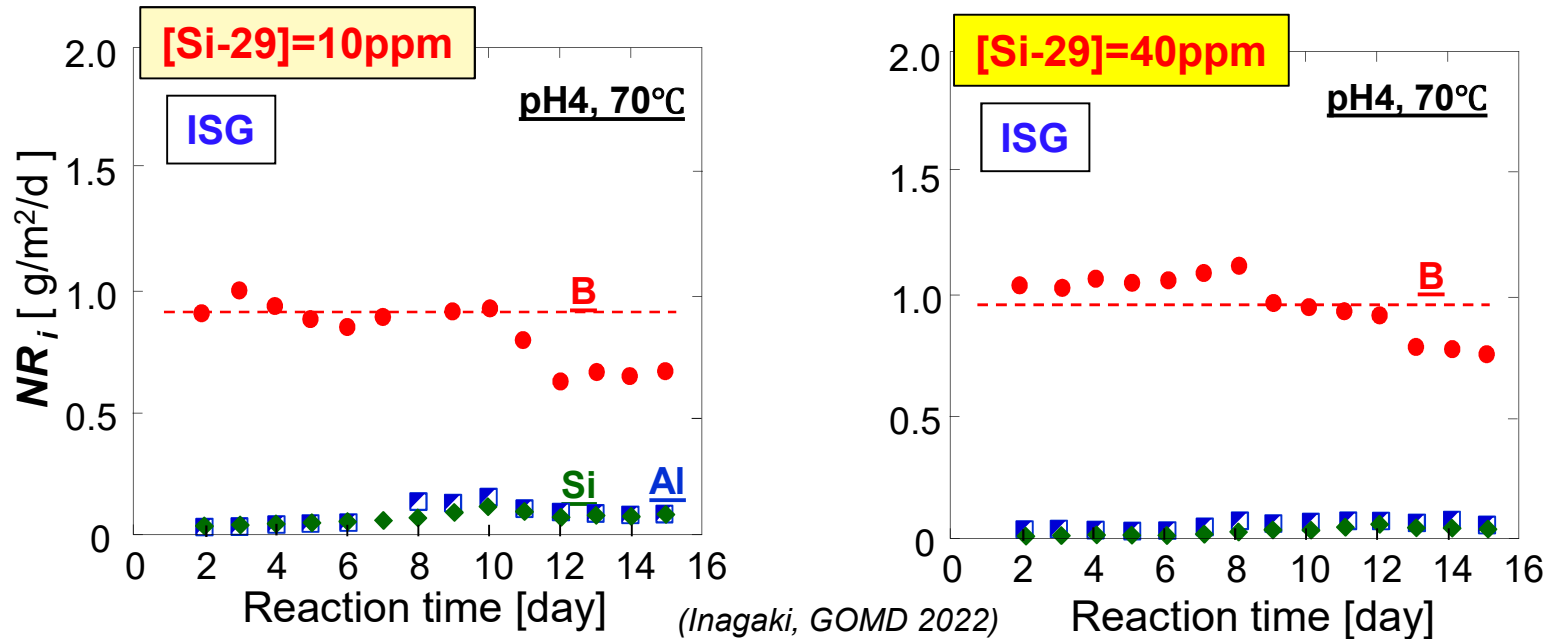
Test results: Effects of C_{Si} on Boron dissolution at pH9



At pH9, Increase in C_{Si} ,

- causes **remarkable decrease in $NR(B)$** as well as **Si & Al.**
- suggested to enhance **the protective surface layer formation.**

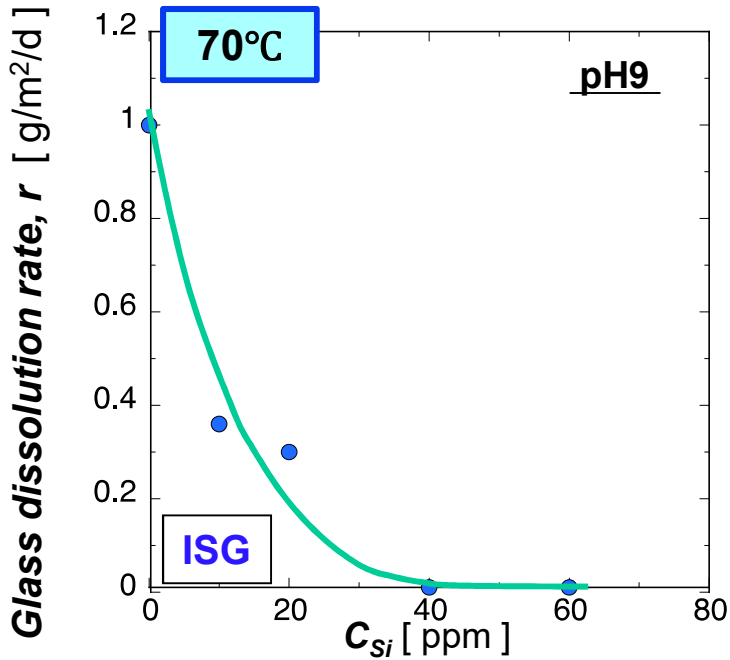
Test results: Effects of C_{Si} on Boron dissolution at pH4



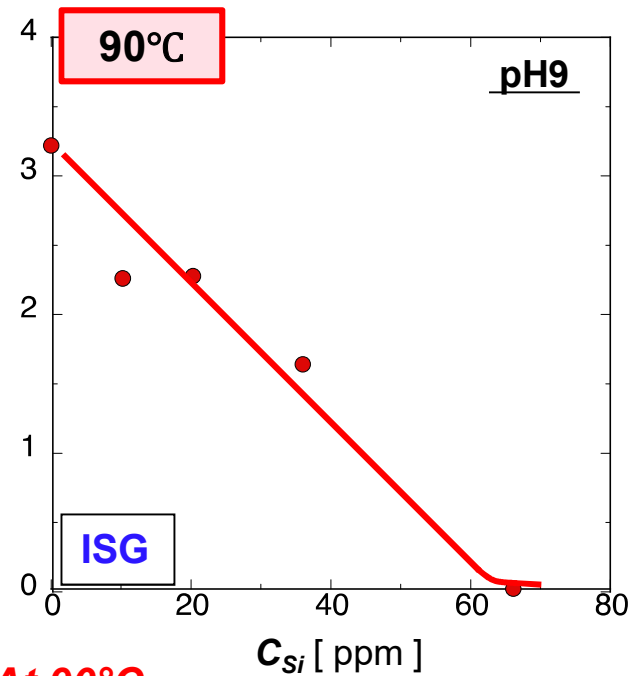
At pH4, Increase in C_{Si}

- has **no effects on $NR(B)$** as well as **Si & Al**,
 - has **no effects on the protective surface layer formation.**
- Effects of C_{Si} on glass dissolution change depending on pH**

Test results: Effect of temp on r (C_{Si}) at pH9



At 70°C,
non-linear relation between r and C_{Si}



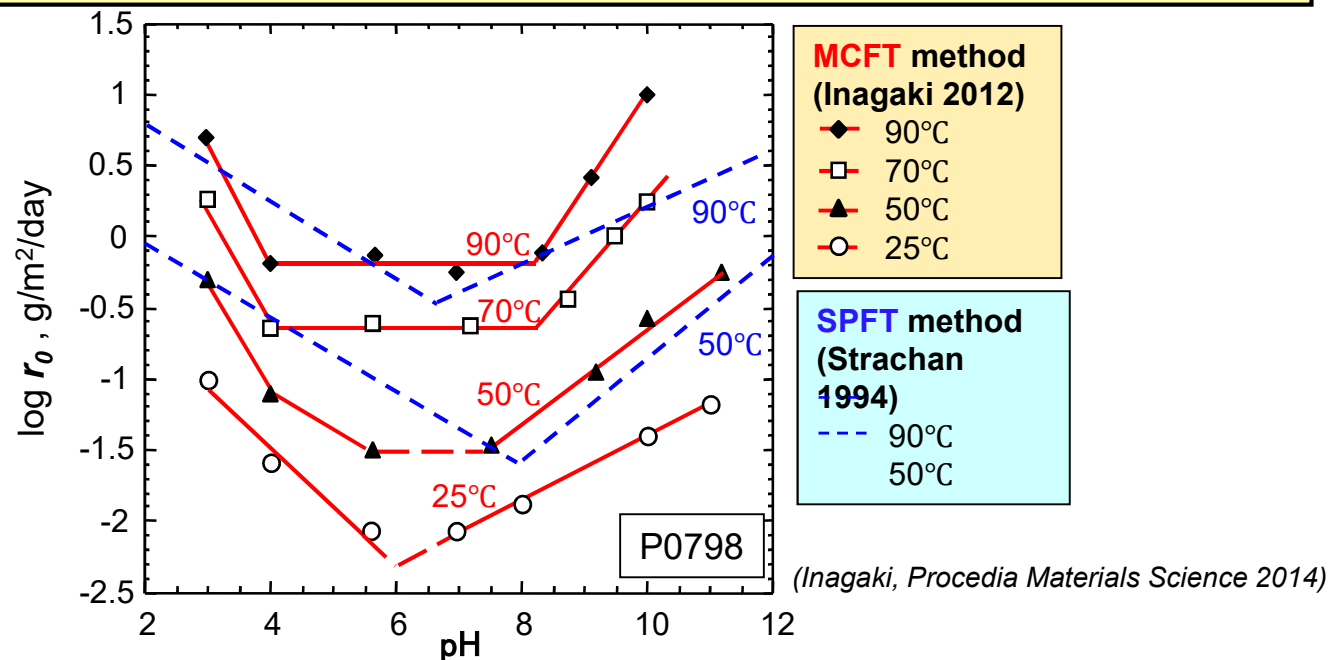
At 90°C,
a good linear relation between r vs C_{Si}

The dissolution mechanism may change by temp at pH9 ?

Test results: Initial dissolution rate, r_0 (pH, temp)

Initial dissolution rate, r_0 , as a function of pH and temp (P0798)

MCFT vs **SPFT**



A certain difference between **MCFT** and **SPFT**

By **MCFT** \Rightarrow "U-shaped" pH dependence

By **SPFT** \Rightarrow "V-shaped" pH dependence